WEST Search History

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DATE: Thursday, April 27, 2006

Hide?	Set Name	Query	Hit Count
		DB=USPT; PLUR=YES; OP=ADJ	
☐	L29	6494220.pn. or 6516815.pn.	2
		DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ	
☐	L28	L27 and l15	61
☐	L27	134/26,27,28,29,36,22.1,22.18,902;438/905,906.ccls.	7696
☐	L26	l21 same (wafer or object or substrate or workpiece or semiconductor)	4
		DB=EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ	
☐	L25	090290199	0
☐	L24	90290199	0
☐	L23	290199	8
☐	L22	9290199	0
		DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ	
☐	L21	((clean$3 or wash$3 or rins$3) adj (support$3 or chuck$3 or piedestal or hold$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent)	46
		DB=EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ	
☐	L20	((clean$3 or wash$3 or rins$3) adj (support$3 or chuck$3 or piedestal or hold$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent)	11
☐	L19	((clean$3 or wash$3) adj (support$3 or chuck$3 or piedestal or hold$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent) with (wafer or object or substrate or workpiece)	2
☐	L18	((clean$3 or wash$3) adj5 (support$3 or chuck$3 or piedestal or hold$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent) with (wafer or object or substrate or workpiece) with rins$3	2
☐	L17	((clean$3 or wash$3 or rins$3) adj5 (support$3 or chuck$3 or piedestal or hold$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent) with (wafer or object or substrate or workpiece)	67
		DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ	
☐	L16	L15 and l9	53
☐	L15	((clean$3 or wash$3 or rins$3) adj5 (support$3 or chuck$3 or piedestal or hold$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent) with (wafer or object or substrate or workpiece)	146
☐	L14	L13 and l9	73
☐	L13	((clean$3 or wash$3) adj5 (support$3 or chuck$3 or piedestal or hold$3)) with	740

		(cup or chamber or reservoir) with (liquid or wet or solution or solvent)	
☐	L12	L11 and l9	164
☐	L11	((clean$3 or wash$3) adj5 (support$3 or chuck$3 or piedestal or hold$3)) with (cup or chamber or reservoir)	3859
		DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ	
☐	L10	L9 and l8	726
☐	L9	134/22.1,22.18,902.ccls.	4186
☐	L8	(clean$3 or wash$3) adj5 (support$3 or chuck$3 or piedestal or hold$3)	74026
☐	L7	L6 and ((clean$3 or wash$3) same cup same (support$3 or chuck$3 or piedestal or hold$3) same rins$3)	4
☐	L6	L5 or l4 or l3 or l2 or l1	24073
☐	L5	ariga-yoshikazu$.in.	6
☐	L4	miyashita-mitsuo$.in.	16
☐	L3	nishioka-yukiko$.in.	47
☐	L2	yonekura-ryosuke$.in.	5
☐	L1	(ebara).as.	24048

END OF SEARCH HISTORY